

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent Application of	)	Attorney Docket No.: <b>SUGI0064</b>
	)	Confirmation No.: 7328
Tadahiro OHMI et al.	)	
	)	Group Art Unit: 1764
Serial No.: 09/773,605	)	
	)	Examiner: Jennifer A. LEUNG
Filed: February 2, 2001	)	
	)	
For: APPARATUS AND REACTOR FOR	)	
GENERATING AND FEEDING HIGH	)	
PURITY MOISTURE	)	

**DECLARATION UNDER RULE 132**

**MAIL STOP: AF**

U.S. Patent and Trademark Office  
Customer Service Window  
Randolph Building  
401 Dulany Street  
Alexandria, VA 22314

Sir:

1. I, Keiichi Hasegawa, state that I am an expert in the field of Mechanical Engineering.  
  
Specifically, I am the chief at Fujikin Incorporated, Osaka High-Tech Research Institute  
  
in Osaka Japan.
2. I am familiar with the above-captioned application, including the drawings. I  
  
understand that the Examiner has rejected certain of the amendments to the claims as  
  
not supported by the drawings.
3. I expect that a person reviewing Fig. 6 originally filed in the present application would  
  
understand it to describe a reflector plate having a thickness exceeding one half of the  
  
distance between the supply passage and the outlet passage.

4. I further expect that a person would understand that the "thickness" of the reflector plate would refer to the thickness at the central portion, and not the thickness at the peripheral edge.
5. I declare under penalty of perjury that the foregoing is true and correct, that all statements made herein of my own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements so made are punishable by fine or imprisonment, or both, under 18 U.S.C. § 1001 and that such willful false statements may jeopardize the validity of the application or any patent issued thereon.

Signed by,

Date: January 27, 2006

Keiichi Hasegawa  
Keiichi Hasegawa  
[INSERT NAME]